

# Zexuan Zhang

## List of Publications by Citations

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The third column is the impact factor (IF) of the journal, and the fourth column is the number of citations of the article.

11 papers	235 citations	5 h-index	11 g-index
11 ext. papers	293 ext. citations	3 avg, IF	2.8 L-index

#	Paper	IF	Citations
11	Breakdown mechanism in 1 kA/cm <sup>2</sup> and 960 V E-mode Ga <sub>2</sub> O <sub>3</sub> vertical transistors. <i>Applied Physics Letters</i> , <b>2018</b> , 113, 122103	3.4	91
10	1230 V Ga <sub>2</sub> O <sub>3</sub> trench Schottky barrier diodes with an ultra-low leakage current of . <i>Applied Physics Letters</i> , <b>2018</b> , 113, 202101	3.4	61
9	The new nitrides: layered, ferroelectric, magnetic, metallic and superconducting nitrides to boost the GaN photonics and electronics eco-system. <i>Japanese Journal of Applied Physics</i> , <b>2019</b> , 58, SC0801	1.4	43
8	2.44 kV Ga <sub>2</sub> O <sub>3</sub> vertical trench Schottky barrier diodes with very low reverse leakage current <b>2018</b> ,		23
7	Polarization-induced 2D hole gases in pseudomorphic undoped GaN/AlN heterostructures on single-crystal AlN substrates. <i>Applied Physics Letters</i> , <b>2021</b> , 119, 162104	3.4	6
6	SpinOrbit torque field-effect transistor (SOTFET): Proposal for a magnetoelectric memory. <i>Applied Physics Letters</i> , <b>2020</b> , 116, 242405	3.4	4
5	Magnetic properties of MBE grown Mn <sub>4</sub> N on MgO, SiC, GaN and Al <sub>2</sub> O <sub>3</sub> substrates. <i>AIP Advances</i> , <b>2020</b> , 10, 015238	1.5	3
4	Very High Density (>10 <sup>14</sup> cm <sup>-2</sup> ) Polarization-Induced 2D Hole Gases Observed in Undoped Pseudomorphic InGa <sub>0.5</sub> N/AlN Heterostructures. <i>Advanced Electronic Materials</i> , 2101120	6.4	3
3	Materials Relevant to Realizing a Field-Effect Transistor Based on SpinOrbit Torques. <i>IEEE Journal on Exploratory Solid-State Computational Devices and Circuits</i> , <b>2019</b> , 5, 158-165	2.4	1
2	Epitaxial Ferrimagnetic Mn <sub>4</sub> N Thin Films on GaN by Molecular Beam Epitaxy. <i>IEEE Transactions on Magnetics</i> , <b>2021</b> , 1-1	2	0
1	Distributed polarization-doped GaN p <sub>0</sub> n diodes with near-unity ideality factor and avalanche breakdown voltage of 1.25 kV. <i>Applied Physics Letters</i> , <b>2022</b> , 120, 122111	3.4	0